

L Number	Hits	Search Text	DB	Time stamp
1	16	250/\$.ccls. and electron adj beam and lens and shield and conductive and resistive	USPAT; EPO; JPO; DERWENT	2003/04/23 08:18
2	151	250/\$.ccls. and electron adj beam and objective adj lens and shield	USPAT; EPO; JPO; DERWENT	2003/04/23 08:49
3	102	250/\$.ccls. and electron adj beam and objective adj lens and electrostatic adj deflector	USPAT; EPO; JPO; DERWENT	2003/04/23 08:26
4	23	250/\$.ccls. and electron adj beam and objective adj lens and electrostatic adj deflector not magnetic	USPAT; EPO; JPO; DERWENT	2003/04/23 08:27
5	10	(250/\$.ccls. and electron adj beam and objective adj lens and electrostatic adj deflector not magnetic) and secondary adj electron	USPAT; EPO; JPO; DERWENT	2003/04/23 08:27
12	20	250/\$.ccls. and electron adj beam and objective adj lens and deflector and auger adj electron	USPAT; EPO; JPO; DERWENT	2003/04/23 10:48
25	6	250/\$.ccls. and electron adj beam and lens and deflector and auger adj electron and capacitor	USPAT; EPO; JPO; DERWENT	2003/04/23 10:41
26	19	250/\$.ccls. and electron adj beam and objective adj lens and deflector and auger adj electron and image	USPAT; EPO; JPO; DERWENT	2003/04/23 10:48